Upscaling of Thin Film Coating Technologies for Energy Storage Applications: Some Case Studies

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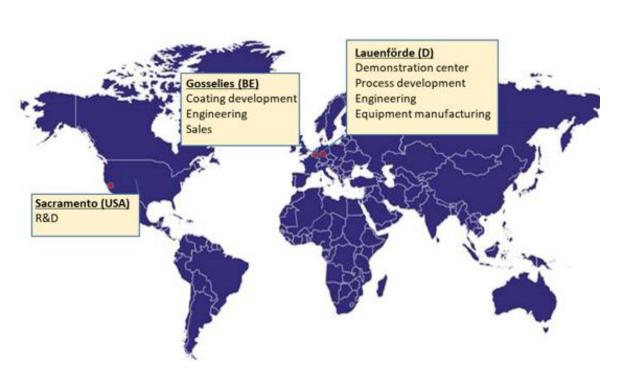


Glass Coating Plant



AGC Plasma Technology Solutions

Bringing AGC's know-how in vacuum coating technology to a broad spectrum of industries outside the glass world



Leveraging on AGC's experience in:

- 1. Operational management of magnetron sputtering lines
- 2. Coating development
- 3. Developing new plasma technologies
- 4. In-house engineering and manufacturing of equipment

Services provided by AGC Plasma:

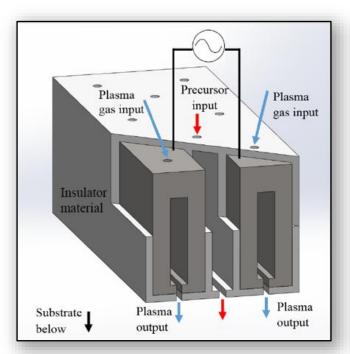
- Product development & prototyping
- 2. Process development and optimization
- 3. Turnkey projects (Engineering, Construction, Commissioning)

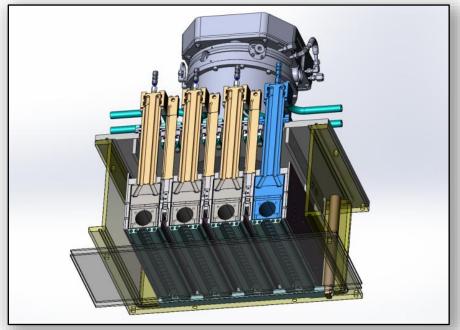




Case Study 1: Silicon Anode Synthesis via PECVD

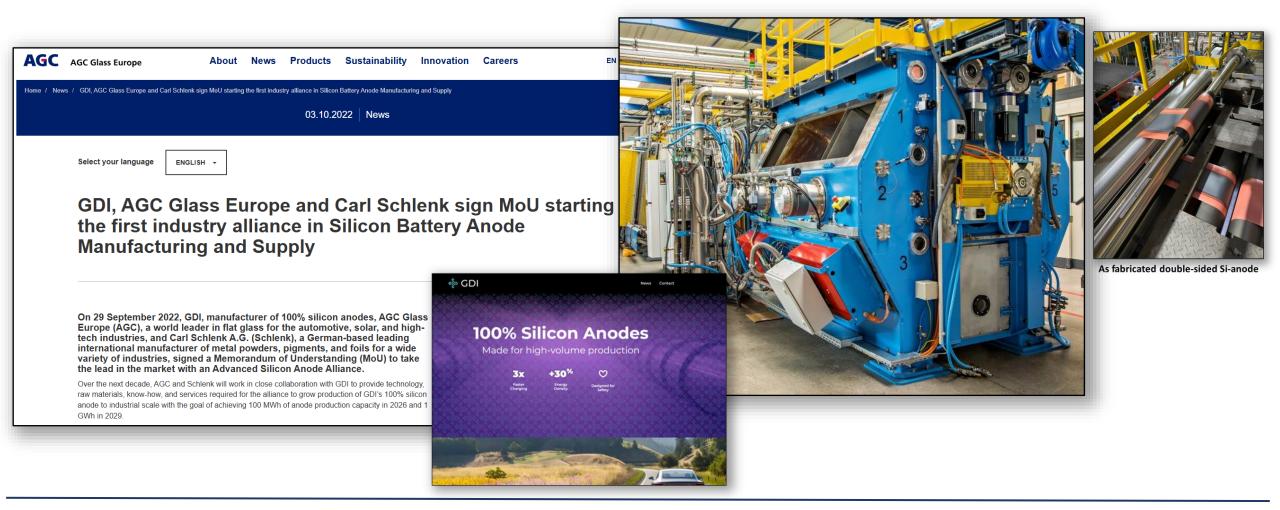
Silicon Anode Synthesis Working Principle PECVD





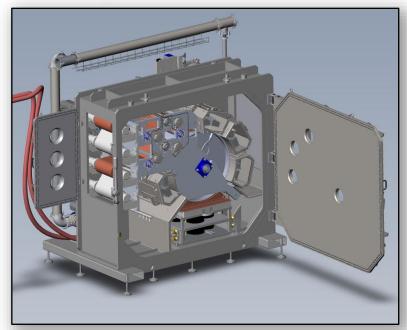


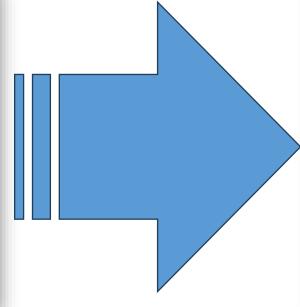
Silicon Anode Synthesis PECVD Integrated into Roll-to-Roll Coater



Case Study 2: Lithium Metal Anode Thermal Evaporation



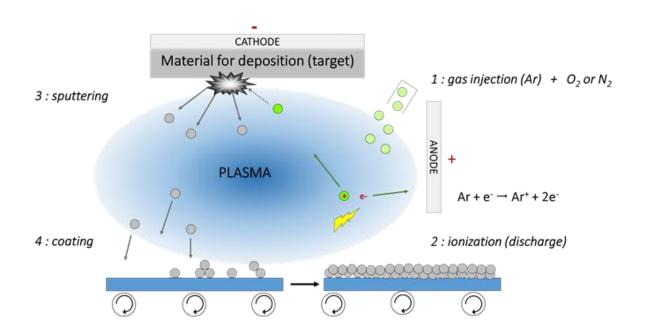


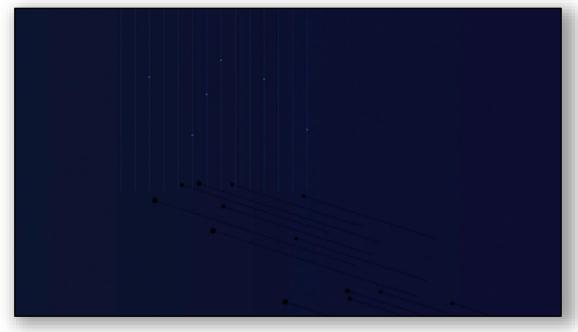




Case Study 3: Magnetron Sputtering of Solid Electrolyte and Cathode

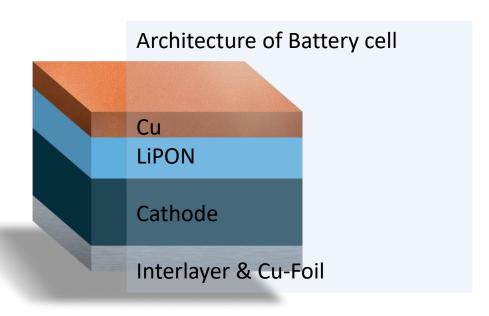






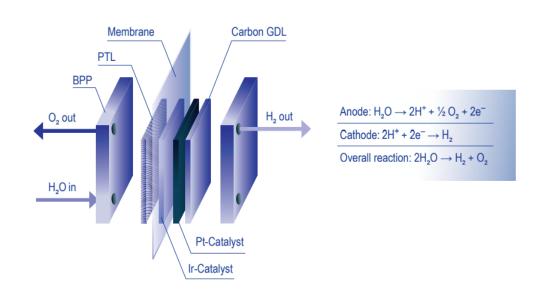
Case Study 3: Magnetron Sputtering of Solid Electrolyte and Cathode





- BTRY uses magnetron sputtering to deposit LiPON electrolyte and cathode.
- **Sputtering insulating materials** like LiPON is challenging and usually need RF sputtering, which is not ideal for mass production. BTRY's technical approach solved this challenge
- AGC supports BTRY by enabling **DC sputtering with a doped LiPON target**, restoring insulation during reactive sputtering.

Case Study 4: Magnetron Sputtering Platinum for Porous Transport Layers of PEM electrolyzers



- Cost-effective platinum coatings via magnetron sputtering: Reduces precious metal usage by enabling ultra-thin, uniform layers on Porous Transport Layers and Bipolar Plates—cutting material costs compared to traditional wet-chemical methods
- Good adhesion with plasma pre-cleaning & undercoat: Ensures durable platinum attachment that enhances corrosion, oxidation resistance, and electrical performance in harsh electrolyzer environments
- •Scalable, eco-friendly PVD process: AGC's modular sputtering equipment (R&D to high-volume) uses no hazardous chemicals, offers reproducible uniform coatings via iOSMB technology, and supports vertical cathode setups to minimize particle contamination

Conclusions

Thin film coating technology is a proven industrial process.

Potential applications in battery & hydrogen manufacturing include:

- 1. Silicon Anodes: PECVD process to convert silane gas into amorphous silicon
- 2. **Lithium Deposition:** Thermal evaporation offers a cleaner, more efficient alternative to lithium foil lamination and allows the integration of a protective top layer in a single step.
- 3. Solid Electrolyte: Sputtering technology can deposit electrical insulating materials
- 4. **Pt protective coating on PTL**: Sputtering of dense thin layers of noble metals as an alternative to electrochemical deposition

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